

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 58-150148

(43)Date of publication of application : 06.09.1983

(51)Int.Cl.

G11B 7/26
G11B 3/70
G11B 11/00
// B29D 17/00

(21)Application number : 57-025902

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(22)Date of filing : 22.02.1982

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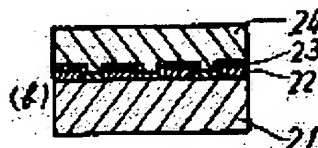
(54) PRODUCTION OF STAMPER

(57)Abstract:

PURPOSE: To form a stamper which is excellent in transferring and replicating characteristics of a fine pattern and is highly resistive to abrasion and corrosion, by forming a stamper layer on the surface of a coating layer by a nickel electrodeposition method then separating the stamper from the recording disc.

CONSTITUTION: A reactive film of photoresist or low m.p. metal is provided on a glass substrate 21 at 0.05W0.1 μ m thickness, and the film thereof is provided with grooves or ruggedness by laser exposure method, whereby a finely patterned layer 22 is formed. An alloy of gold and nickel is vapor-deposited on the layer 22 at the thickness necessary for nickel electrodeposition, whereby a conductive film 23 is obtained. A nickel layer

24 is formed on the resulted film 23. When the layer 24 obtained in such a way is separated from a resist recording disc 21, the resist 22 remains on the layer 24; therefore, the resist 22 is removed by using a stripping soln. for resist, then the stamper consisting of the gold or gold-nickel alloy film 23 having the surface transferred with the fine patterns of the recording disc with good reproducibility and the layer 24 is obtained.



LEGAL STATUS

[Date of request for examination]

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]

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